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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR .	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
10/735,989	12/15/2003	Somenath Mitra	436/12	4147		
27538 7	590 03/28/2005	EXAMINER				
KAPLAN & GILMAN , L.L.P. 900 ROUTE 9 NORTH WOODBRIDGE, NJ 07095			FASTOVSKY, LEONID M			
			ART UNIT	PAPER NUMBER		
			3742			

DATE MAILED: 03/28/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application	n No	Applicant(s)				
Office Action Summary		10/735,98		MITRA ET AL.		6		
		Examiner		Art Unit	1			
		Leonid M F	- astovsky	3742				
The	MAILING DATE of this communication				ddress			
Period for Rep								
THE MAILIN - Extensions of after SIX (6) N - If the period fo - If NO period fo - Failure to reply Any reply rece	NED STATUTORY PERIOD FOR F NG DATE OF THIS COMMUNICAT time may be available under the provisions of 37 of IONTHS from the mailing date of this communicat or reply specified above is less than thirty (30) days or reply is specified above, the maximum statutory or within the set or extended period for reply will, by ived by the Office later than three months after the term adjustment. See 37 CFR 1.704(b).	TON. CFR 1.136(a). In no eve tion. s, a reply within the statu period will apply and will y statute, cause the appl	nt, however, may a reply be tin tory minimum of thirty (30) day I expire SIX (6) MONTHS from ication to become ABANDONE	nely filed s will be considered time the mailing date of this of D (35 U.S.C. § 133).				
Status				•				
1)⊠ Respo	onsive to communication(s) filed on	15 December 20	<u>003</u> .	•				
·= ·	his action is FINAL . 2b) This action is non-final.							
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of	Claims							
· _	(s) <u>1-20</u> is/are pending in the applic	cation.						
•	4a) Of the above claim(s) is/are withdrawn from consideration.							
· ·	(s) is/are allowed.							
6)⊠ Claim	☑ Claim(s) <u>1-20</u> is/are rejected.							
7)☐ Claim	Claim(s) is/are objected to.							
8) Claim	(s) are subject to restriction	and/or election re	equirement.					
Application Pa	pers							
9)∏ The sp	pecification is objected to by the Ex	aminer.						
10)⊠ The drawing(s) filed on <u>15 December 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.								
Applic	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
11) The oa	ath or declaration is objected to by	the Examiner. No	te the attached Office	Action or form P	TO-152.			
Priority under	35 U.S.C. § 119	•						
12)∏ Ackno	wledgment is made of a claim for fo	oreign priority und	der 35 U.S.C. § 119(a)-(d) or (f).				
a)∐ All	b) Some * c) None of:		,		•			
1.	1. Certified copies of the priority documents have been received.							
2.	Certified copies of the priority docu	uments have bee	n received in Applicati	on No				
3.□	Copies of the certified copies of th	e priority docume	ents have been receive	ed in this Nationa	l Stage			
	application from the International E	•	, ,,					
* See the	e attached detailed Office action for	a list of the certi	fied copies not receive	ed.				
Attachment(s)								
	erences Cited (PTO-892)		4) Interview Summary	(PTO-413)				
2) Notice of Dra	ftsperson's Patent Drawing Review (PTO-9	•	Paper No(s)/Mail D	ate	O 153)			
	Disclosure Statement(s) (PTO-1449 or PTO/ Mail Date	/SB/08)	5) Notice of Informal F 6) Other:	ғасені Аррисацоп (РТ	U-132)			

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DETAILED ACTION

Specification

1. The abstract of the disclosure is objected to because it contains an extraneous word "comprising" (line 2). Correction is required. See MPEP § 608.01(b).

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 3. Claims 1-2, 5, 10-11,14-15 and 18 are rejected under 35 U.S.C. 102(e) as being anticipated by Jun et al (6,582,987).

Jun teaches a microheater and method of fabricating the microheater for microfluidic devices comprising a microchannel 202 formed on a silicon substrate 201 and a conductor- microheater 214 formed in the microchannel 202 and comprising a metal layer 215 (col. 7, lines 10-17).

As for claim 15, Jun teaches etching of the substrate 201 (col. 6, lines 60-65).

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Claim Rejections - 35 USC § 103

4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 3 and 6-7 and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jun in view of Ferguson (2003/0209534).

Jun discloses substantially the claimed invention, but does not disclose quartz and borosilicate glass. Ferguson discloses resistive heating systems with a substrate 202 comprising quartz and borosilicate glass (page 10, [0068]). It would have been obvious to one having ordinary skill in the art to modify Jun's invention to include the substrate comprising quartz and borosilicate glass as taught by Ferguson in order to provide a more rigid structure for the microheater.

As to claim 3 and the limitation of the conductor comprising an aluminum alloy with 99% aluminum and silicon and copper, it is deemed that the material used for conductor would be chosen by user having a desired result in mind. Therefore it would have been obvious to have made the conductor made out of 99% aluminum and silicon and copper as to obtain the result wanted by the user.

6. Claims 4 and 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jun in view of Yamazaki (6,165,876) and further in view of Ueno et al (2002/00224662). Jun discloses substantially the claimed invention, but does not disclose a substrate comprising a polished silicon wafer, and a conductor-heater comprising boron ions.

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Yamazaki discloses a method of doping a silicon film 203 with boron ion (col. 15, lines 1-18). Ueno discloses a microfluidic device having a heater 3 with a mirror- polished substrate (page 5, [0094]). It would have been obvious to one having ordinary skill in the art to modify Jun's invention to include a boron doped substrate as taught by Yamazaki and a polished substrate as taught by Ueno and a conductor comprising boron ions as taught by Yamazaki in order to assure better heating conditions for the microheater.

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- 7. Claims 16-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jun in view of Yamazaki. Jun in view of Yamazaki discloses substantially the claimed invention, but does not teach boron ion implantation. Yamazaki teaches a method of implanting boron (col. 15, lines 1-10). It would have been obvious to one having ordinary skill in the art to modify the invention of Jun and Yamazaki to provide a method for fabricating a microheater because prior art references do teach performing a process and also structure limitations of the invention.
- 8. Claims 9, 13 and 20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jun in view of Gaitan et al (5,464,966).

Jun discloses substantially the claimed invention, but does not discloses a glass layer disposed on the conductior-heater. Gaitan discloses a micro-hotplate device having a conductor heater 5 comprising a glass-silicone layer 13 (Fig. 5). It would have been obvious to one having ordinary skill in the art to modify Jun's invention to include a glass-silicone oxide layer as taught by Gaitan in order to provide protective insulation.

9. Claim 19 is rejected under 35 U.S.C. 103(a) as being unpatentable over Jun.

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Jun discloses substantially the claimed invention including a conductor-heater 214 comrising a metal layer 215, but does not specify the matal material. It would have been obvious to one having ordinary skill in the art to modify Jun's invention to include the conductor comprising aluminum as an obvious functional equivalent.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Leonid M Fastovsky whose telephone number is 571-272-4778. The examiner can normally be reached on M-Th. 8.00 am -6.00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robin Evans can be reached on 571-272-4777. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Leonid M Fastovsky

Examiner Art Unit 3742

Imf

ROBIN O. EVANS
PRIMARY EXAMINER